

# Electrochemical CO<sub>2</sub> reduction on Cu<sub>2</sub>O-derived copper nanoparticles: controlling the catalytic selectivity of hydrocarbons†

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The catalytic activity and hydrocarbon selectivity in electrochemical carbon dioxide (CO<sub>2</sub>) reduction on cuprous oxide (Cu<sub>2</sub>O) derived copper nanoparticles is discussed. Cuprous oxide films with [100], [110] and [111] orientation and variable thickness were electrodeposited by reduction of copper(II) lactate on commercially available copper plates. After initiation of the electrochemical CO<sub>2</sub> reduction by these oxide structures, the selectivity of the process was found to largely depend on the parent Cu<sub>2</sub>O film thickness, rather than on the initial crystal orientation. Starting with thin Cu<sub>2</sub>O films, besides CO and hydrogen, selective formation of ethylene is observed with very high ethylene-to-methane ratios (~8 to 12). In addition to these products, thicker Cu<sub>2</sub>O films yield a remarkably large amount of ethane. Long term Faradaic efficiency analysis of hydrocarbons shows no sign of deactivation of the electrodes after 5 hours of continuous experiment. Online mass spectroscopy studies combined with X-ray diffraction data suggest the reduction of the Cu<sub>2</sub>O films in the presence of CO<sub>2</sub>, generating a nanoparticulate Cu morphology, prior to the production of hydrogen, CO, and hydrocarbons. Optimizing coverage, number density and size of the copper nanoparticles, as well as local surface pH, may allow highly selective formation of the industrially important product ethylene.

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## Introduction

Carbon dioxide (CO<sub>2</sub>) is the thermodynamically stable product of most hydrocarbon feedstock combustion processes and a significant contributor to the greenhouse effect.<sup>1</sup> The accumulation of CO<sub>2</sub> in the atmosphere has an impact on climate change and could threaten the environment and eventually the worldwide economy.<sup>2,3</sup> The conversion of CO<sub>2</sub> into useful products and chemicals is thus a very attractive research area.<sup>4,5</sup> A currently proposed approach is the electrocatalytic reduction of CO<sub>2</sub> where the electrons are supplied from renewable energy sources, such as photovoltaics, wind and blue energy.<sup>6–8</sup> However, CO<sub>2</sub> reduction into fuels is anticipated to be very challenging, due to the necessary multiple number of proton-coupled electron transfer steps.<sup>9</sup>

Many polycrystalline metals have been analyzed for their activity towards electrocatalytic CO<sub>2</sub> reduction.<sup>10</sup> Among the metal electrodes, copper is the most extensively studied since it is the only metal capable of producing hydrocarbons from CO<sub>2</sub> with reasonable Faradaic efficiencies (FE) in aqueous solutions at ambient conditions of temperature and pressure.<sup>11,12</sup> However, high overpotentials required for the activation of CO<sub>2</sub> and rapid degradation of the catalytic activity are the major obstacles for commercializing the process.<sup>13,14</sup> Even though the deactivation of the catalytic activity is reported to be suppressed by preparing electrolytes *via* pre-electrolysis or applying anodic pulses,<sup>14,15</sup> the reproducibility and compatibility of these preparation steps are not appropriate for large scale application. The key issue in the current state of electrocatalytic CO<sub>2</sub> reduction is to find a stable and robust cathode material that could selectively convert CO<sub>2</sub> and H<sub>2</sub>O to useful products at low overpotentials.<sup>16</sup> Energy efficient processes at low overpotentials were reported using ionic liquids as solvent<sup>17</sup> or pyridine as additive.<sup>18</sup> Besides low current densities reported in these studies, the effects of the solvents on the electrolyzer are unknown. The modification of polycrystalline copper surfaces with different structures might allow for a stable electrode performance in aqueous solutions and energy efficient transformation routes towards energy dense products.<sup>19</sup>

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Growing oxide films on top of a metallic surface is a widely used method of producing structured electrode surfaces.<sup>20,21</sup> Methanol was anticipated to form on cuprous oxide (Cu<sub>2</sub>O) coated Cu surfaces.<sup>22,23</sup> However, deactivation of these electrodes for methanol production after short reaction times suggests conversion of the oxide films in the process. Recently, thermally produced thick oxide films were reported to decrease the overpotential of product formation without losing activity for extended electrolysis time.<sup>19,24–26</sup> The CO<sub>2</sub> electrocatalytic reduction process on these copper oxide films was proposed to take place on *in situ* produced copper oxide nanoparticles during cathodic reconstruction of the Cu<sub>2</sub>O oxide films. The selectivity of the thick films was predominantly towards carbon monoxide (CO) and formic acid at low potentials, contrary to thin oxide films which mainly produced methanol.<sup>19</sup> Although several aspects of the thermal-oxide derived electrodes have been validated by Kanan and coworkers, the selectivity towards hydrocarbons, and mechanistic pathways explaining formation thereof, have not been extensively described.

In this study, the performance of electrochemically produced Cu<sub>2</sub>O coated copper substrates towards CO<sub>2</sub> reduction is evaluated in terms of selectivity, activity and long term stability. Cu<sub>2</sub>O films with surfaces exposing different crystal facets were prepared *via* controllable, facile, well established electrochemical methods, and the resulting catalytic performance was evaluated using gas chromatography and online electrochemical mass spectroscopy (OLEMS). The effects of the crystal orientation, oxidation state and thickness of the films on the resulting CO<sub>2</sub> electrocatalytic reduction product selectivity will be extensively discussed, with focus on the formation of methane, ethylene and ethane.

## Experimental section

### Chemicals, materials and Cu<sub>2</sub>O film deposition

All working solutions were prepared and all glassware cleaned using deionized water (Millipore MilliQ, 18.2 MΩ cm). Cuprous oxide films were electrodeposited onto copper plates (Alfa Aesar, 99.99%) from Cu<sup>2+</sup> containing solutions prepared using 0.4 M CuSO<sub>4</sub> (Sigma Aldrich, ≥99%) and 3 or 4 M lactic acid (Sigma Aldrich) at 60 or 70 °C, according to the procedures described elsewhere.<sup>27</sup> The pH of the solution was carefully adjusted between 9 and 12 using solid NaOH (Sigma Aldrich, 98%) and a 1 M NaOH solution. Copper plates were prepared by mechanical polishing using emery paper, followed by cleaning ultrasonically in ethanol and water. The electrodeposition was conducted in a standard three-electrode cell where platinum mesh and Ag/AgCl in 3 M NaCl served as counter and reference electrodes, respectively. Galvanostatic deposition was performed at 0.8 and 2 mA cm<sup>-2</sup> using a potentiostat/galvanostat (PAR, Versastat 3). Specifically, the crystalline morphology was controlled by adapting experimental parameters. Cu<sub>2</sub>O films were deposited using a molar lactic acid (LA)/Cu<sup>2+</sup> ratio of 10 and 7.5 at pH 12 and pH 9, respectively. The deposition times of the films varies depending on the current density applied.

Deposition was continued until a total charge of 7 C cm<sup>-2</sup> was passed through the cell for all samples. Series of [110] oriented films were prepared by passing a variable amount of total electrical charge through the electrochemical cell, ranging from 3 to 11 C cm<sup>-2</sup> to control the thickness of the film.

The crystalline phase of the films was determined using X-ray diffraction (a Bruker D2 Phaser, equipped with a Cu-Kα radiation source operating at 30 kV and 10 mA). Scanning Electron Microscope (SEM) images were taken using a Phillips FEI XL30 FEG-ESEM and FEI Sirion HR-SEM.

### Electrochemical CO<sub>2</sub> reduction experiments

Electrochemical CO<sub>2</sub> reduction was carried out in a glass cell using a three electrode assembly at room temperature and pressure. 85 ml of 0.1 M KHCO<sub>3</sub> (Sigma Aldrich, 99.99%) was used as electrolyte at pH 6.8, as obtained after saturation with CO<sub>2</sub> (Linde Gas Benelux 99.99%). Pt mesh was used as counter electrode and was separated from the working electrode using a proton exchange Nafion 112 membrane (Sigma Aldrich). Ag/AgCl in 3 M NaCl was used as a reference electrode and potentials were recalculated with reference to the Reversible Hydrogen Electrode (RHE) scale after the experiments. CO<sub>2</sub> was continuously purged at a rate of 20 ml min<sup>-1</sup> for 30 minutes before each experiment, to attain saturation of the electrolyte. Then the flow rate was decreased to 5 ml min<sup>-1</sup>, during which electrochemical reduction was conducted. The continuously purged headspace of the reactor was approximately 45 ml and the reactor effluent sampled directly *via* gas chromatography (GC) once every 6 min. The GC was equipped with two different columns (ShinCarbon 2 m micropacked column and Rtx-1) for simultaneous separation of CO, CO<sub>2</sub>, H<sub>2</sub> and hydrocarbons. A thermal conductivity detector (TCD) and flame ionization detector (FID) were used to perform the quantitative analysis of the gas phase products. The time needed to reach the steady state concentration was approximately 40 minutes (see Fig. S1, ESI<sup>†</sup>), so all experiments were conducted for at least 1 hour before gas phase measurement. A control cathodic experiment was conducted at -1.1 V *vs.* RHE by purging N<sub>2</sub> through the reactor since the decomposition of organics associated with the electrodeposition can also yield hydrocarbons.<sup>28</sup> No hydrocarbon or CO formation were detected in the absence of CO<sub>2</sub>. Liquid products formed during the electrolysis were analyzed off line using High Performance Liquid Chromatography (HPLC) (Prominence HPLC, Shimadzu; Aminex HPX 87-H column, Biorad).

### Electrochemical surface area measurements

The relative surface roughness factors of the nanoparticulate surfaces were calculated by measuring their capacitance values in 0.5 M H<sub>2</sub>SO<sub>4</sub>. Pt mesh was used as a counter electrode and Ag/AgCl was used as reference electrode. After reducing the layers in 0.1 M KHCO<sub>3</sub>, cyclic voltammetry (CV) curves were obtained with different scan rates in the potential region where non-faradaic processes occur. The slope of the current density *vs.* scan rate yielded the capacitance value which was normalized to bare copper, to obtain the surface roughness factors (Fig. S2a and S2b, ESI<sup>†</sup>).

## OLEMS measurements

Online electrochemical mass spectroscopy (OLEMS) was used to detect gaseous products formed during CO<sub>2</sub> reduction.<sup>29,30</sup> The products were collected with a small hydrophobic tip that was positioned close to the electrode (about 10 μm) with the aid of a camera. The tip was constructed as a porous Teflon cylinder with a diameter of 0.5 mm and an average pore size of 10–14 μm in a Kel-F holder. The tip was connected to the mass spectrometry chamber with a PEEK capillary. Before experiments the tip was cleaned in a solution of 0.2 M K<sub>2</sub>Cr<sub>2</sub>O<sub>7</sub> in 2 M H<sub>2</sub>SO<sub>4</sub> and rinsed thoroughly with Millipore water. A secondary electron multiplier voltage of 2400 V was used for detection of products in a Balzers quadrupole mass spectrometer, except for hydrogen where a voltage of 1200 V was used. The products were measured while changing the potential of the electrode from 0.0 V to −1.4 V vs. RHE and back at 1 mV s<sup>−1</sup>.

## Results and discussion

### Electrochemical deposition of Cu<sub>2</sub>O films

SEM images and the corresponding XRD patterns of as prepared Cu<sub>2</sub>O films are shown in Fig. 1a–d. The XRD patterns acquired clearly indicate that the crystals obtained are preferentially oriented in either [100], [110] and [111] directions, depending on the applied synthesis conditions. The films grown at pH 12 with a current density of 0.8 mA cm<sup>−2</sup> exhibit triangular pyramids oriented in the [110] direction where the (100) and (010) facets are exposed.<sup>31</sup> Increasing the current density to 2 mA cm<sup>−2</sup> at pH 12 favors the growth in [100] directions with three-faced pyramids, where the sides of the pyramids expose (111) facets.<sup>32</sup>

At pH 9 the morphology of the crystals evolved to four sided pyramids oriented in the [100] direction exposing (111) facets.<sup>27</sup>

Electrodeposition of Cu<sub>2</sub>O films has been extensively studied and well established from Cu<sup>2+</sup> solutions in the presence of the surfactants and complexing agents, such as sodium dodecyl sulfate, or lactic acid.<sup>33–35</sup> Formation of [111] and [100] oriented films was studied previously extensively,<sup>32,36–38</sup> whereas [110] oriented films were reported in a couple of studies and were found to be stable in a very narrow pH range.<sup>31</sup> Our attempts to reproduce [110] oriented films were successful, but the orientation of the films was found to be different at increasing thickness, which is most likely due to a change in pH and copper concentration during the electrodeposition.<sup>32</sup> Nevertheless, we found that increasing the amount of lactic acid at pH 12 yields [110] oriented films with low current densities in a reproducible way.

### Electrochemical CO<sub>2</sub> reduction in 0.1 M KHCO<sub>3</sub> on different facets of Cu<sub>2</sub>O films

The distribution of the gaseous products obtained during the CO<sub>2</sub> electrochemical reduction at a cathodic potential of −1.1 V vs. RHE is presented in Fig. 1e. It can be seen that only minor differences exist in the FE of the gaseous products between the different predominant crystal oriented films. In particular, CO, methane, ethylene and some ethane were gaseous products observed of CO<sub>2</sub> electrochemical reduction. CO desorbs from the surface and is a well-known intermediate for the formation of ethylene and methane.<sup>10</sup> Ethylene was the major product among the hydrocarbons for all of the samples with a small variation in ethylene/methane ratio observed. Ethane formation was detected with low FE for all of the samples investigated. Unfortunately, we were not able to compare the data to the performance of polycrystalline copper electrodes: complete deactivation of polycrystalline

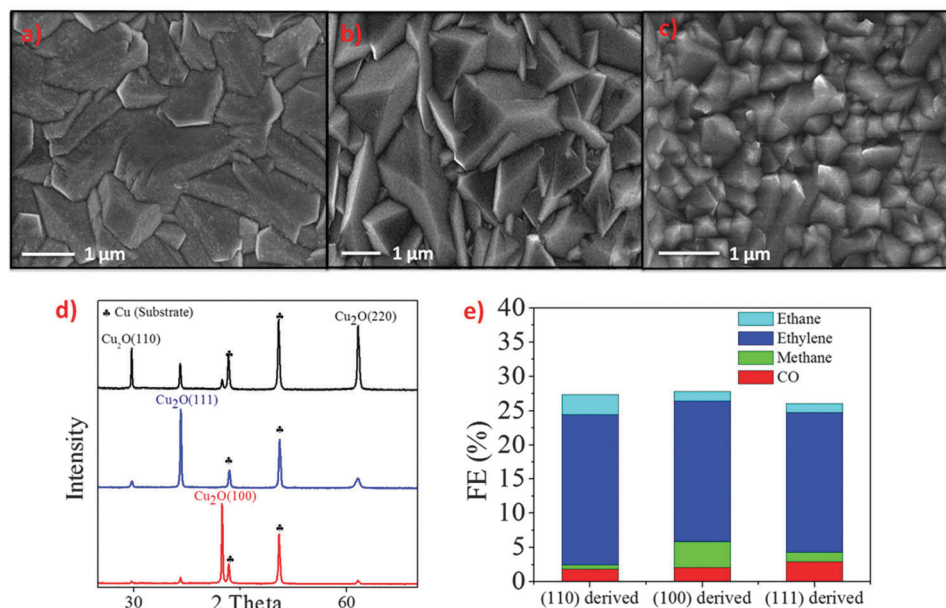


Fig. 1 SEM images of as deposited Cu<sub>2</sub>O films with predominant (a) [110], (b) [111] and (c) [100] orientations. (d) X-ray diffraction patterns of Cu<sub>2</sub>O films electrochemically deposited on copper substrate. (e) FE of gaseous products from CO<sub>2</sub> reduction at −1.1 V vs. RHE in 0.1 M KHCO<sub>3</sub> solution for oxides having different crystal orientation.

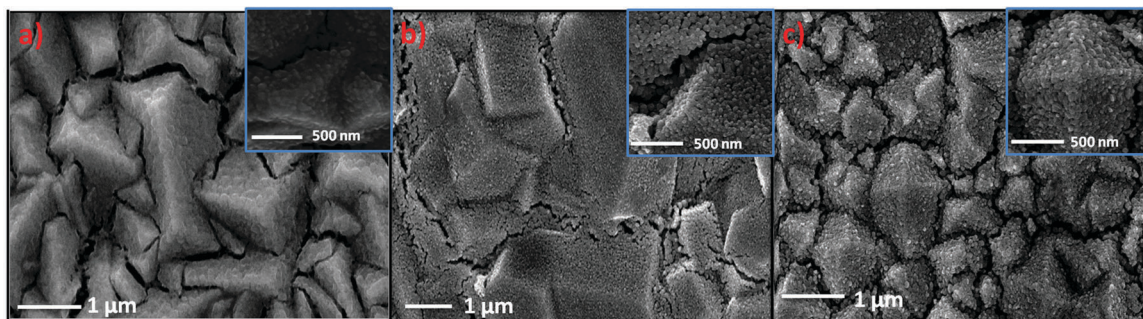


Fig. 2 SEM images of copper nanoparticles obtained after reaction from oxides in the (a) [110], (b) [111] and (c) [100] orientations. Corresponding SEM images are also shown with high resolution images in the inset.

copper was observed, before steady state was reached (the reactor was operated as CSTR).

XRD patterns obtained of the samples after the CO<sub>2</sub> experiments were acquired and show that only diffraction lines due to metallic copper are present (see Fig. S3, ESI†). Thus, in the potential range applied here for CO<sub>2</sub> electrochemical reduction (−0.2 V to −1.1 V vs. RHE), none of the Cu<sub>2</sub>O films were stable, and reduced to metallic copper. The SEM images of the samples shown in Fig. 2a–c signify different microscopic morphology of the films obtained after the reduction process, when compared to that before the reduction. When compared to those in Fig. 1, the smooth surfaces of the pyramids roughened and the films cracked at the intersection of the pyramids. The higher magnification insets in Fig. 2 show that pyramids are now composed of spherical nanometer sized copper domains. As it will be established further using OLEMS studies, CO<sub>2</sub> reduction apparently did not proceed on Cu<sub>2</sub>O, but rather on *in situ* formed metallic copper nanoparticles. Even though there is no distinct difference between the samples in terms of their corresponding product selectivity as a function of initial Cu<sub>2</sub>O orientation, suggesting the structure of the *in situ* formed copper nanoparticles is not much different, the observed high ethylene selectivity of the electro-catalytically active copper surfaces is distinctly different from the selectivities previously reported for polycrystalline copper, and oxide derived copper nanoparticles.<sup>12,19,26</sup> Electro-polished polycrystalline copper is well known to produce methane as the major product within the investigated potential range,<sup>13</sup> while ethane was reported to be a dominant product on copper derived from thermally formed oxide films.<sup>19</sup> Further, in agreement with our product distribution, anodically created oxide films were found to lead to formation of predominantly ethylene, but for these films ethane formation was not observed.<sup>26</sup> To further analyze the effect of the structure of the oxide derived copper nanoparticle layer on hydrocarbon selectivity, layers with different thickness were prepared and evaluated in electrocatalytic CO<sub>2</sub> reduction.

### Electrochemical CO<sub>2</sub> reduction in 0.1 M KHCO<sub>3</sub> on (110) Cu<sub>2</sub>O films of increasing thickness

The XRD patterns of a series of [110] oriented Cu<sub>2</sub>O films prepared by passing a different amount of total electrical charge through the electrochemical cell, are shown in Fig. 3a.

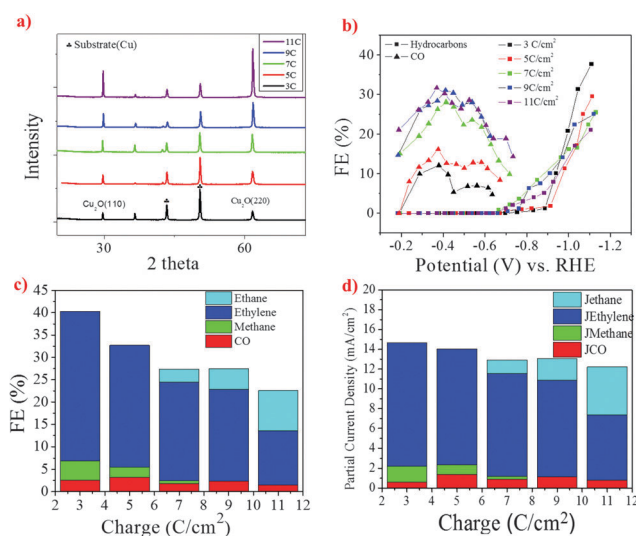


Fig. 3 (a) The X-ray diffraction patterns of the [110] oriented Cu<sub>2</sub>O films prepared by changing the total charge passed through the cell. (b) FEs of CO and hydrocarbons at different potentials as a function of initial thickness of the films (c) FE and (d) partial current density of gaseous products from CO<sub>2</sub> reduction at −1.1 V vs. RHE in 0.1 M KHCO<sub>3</sub> solution as a function of initial thickness of the films (FEs of CO are given in a limited potential range for clarity).

It can be seen that the diffraction line due to the [110] plane becomes more predominant as the thickness of the films increases. Likewise, the intensity of the metallic copper diffraction lines from the substrate decreases, as the thickness of Cu<sub>2</sub>O films increases. Growth in the [100] and [111] directions has been reported to be restricted to a localized or spotty deposition, suggesting growth of our films is more homogeneous to explain the observed preferred [110] crystal orientation of our films.<sup>37</sup> CO<sub>2</sub> reduction on the thus prepared electrodes was performed in the potential range between −0.2 and −1.1 V vs. RHE. A plot of CO and hydrocarbon FE (%) vs. the applied cathodic potential is shown in Fig. 3b. For the samples having higher initial oxide thicknesses, CO formation starts at very low overpotentials (∼−0.1 V) and reaches a maximum between −0.3 and −0.5 V vs. RHE. These observations are consistent with findings on thermally induced oxide derived films of copper.<sup>19</sup> At higher applied potentials, the FE towards CO

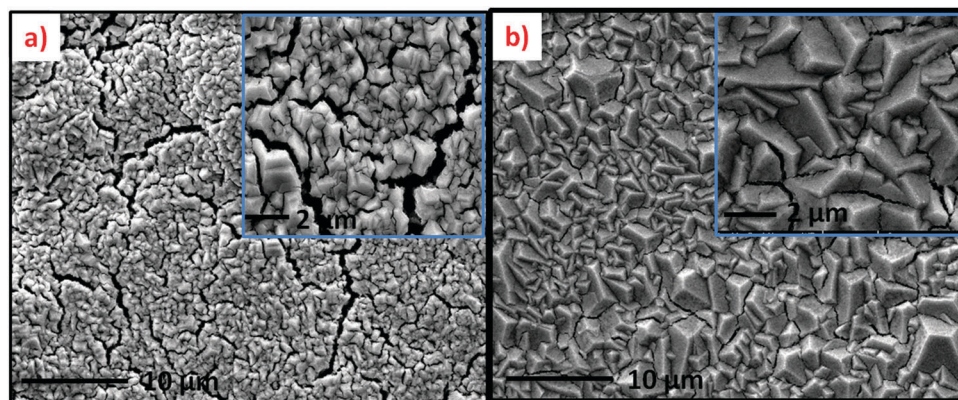


Fig. 4 SEM image of the [110] oriented (a) thinnest ( $3 \text{ C cm}^{-2}$ ) and the (b) thickest ( $11 \text{ C cm}^{-2}$ )  $\text{Cu}_2\text{O}$  samples after the electrochemical  $\text{CO}_2$  reduction.

decreases, and hydrocarbon products start to evolve with onset potentials between  $-0.65$  and  $-0.75 \text{ V vs. RHE}$ . The change in hydrocarbon product distribution (FE (%)) at cathodic potential of  $-1.1 \text{ V vs. RHE}$  as a function of thickness is given at Fig. 3c. A major observation is that the distribution of the hydrocarbon products changes distinctively from methane to ethane, CO being relatively constant, and ethylene continuously decreasing. No deactivation towards the hydrocarbon production was observed for the thinnest samples over the course of 5 hours (Fig. S4, ESI<sup>†</sup>), as compared to polycrystalline copper which was found to rapidly deactivate within 40 minutes.<sup>14</sup>

SEM images of the thinnest ( $3 \text{ C cm}^{-2}$ ) and the thickest ( $11 \text{ C cm}^{-2}$ )  $\text{Cu}_2\text{O}$  samples after the electrochemical  $\text{CO}_2$  reduction process are shown in Fig. 4a and b, respectively. The morphology of the thinnest [110] oriented films is not well pronounced, whereas thicker films show characteristic triangular pyramid morphology. It can be seen that the increase in the initial oxide films thickness increases the coverage of the pyramids, which are again composed of the aggregated copper nanoparticles after reduction. As the thickness of the initial oxide films increases, the size of the cracks between the overlapping pyramids decreases and the individual pyramids start to form continuous films. Sample surface roughness, relative to that of bare copper, was measured and is tabulated in Table 1. As the oxide layer thickness increases, the roughness factors of the *in situ* formed nano particulate copper surface increase as well, ranging from 11 for an oxide derived layer produced at  $3 \text{ C cm}^{-2}$  to 65 for an oxide derived layer produced at  $11 \text{ C cm}^{-2}$ . Additionally, the increase in the geometrical current density as a

function of initial oxide layer thickness confirms the increase in surface roughness (Fig. S5, ESI<sup>†</sup>).

Even though the FE of the hydrocarbon products clearly decreases for increasing layer thickness (*i.e.* the selectivity decreases), the overall current density increases (Fig. S5, ESI<sup>†</sup>), and hence the decrease in partial current density values (calculated by the product of the overall current density and the sum of the FE of the gaseous products) is not as significant (Fig. 3d). In other words, the production rate of hydrocarbons (and  $\text{CO}_2$  conversion rate) only slightly decreases (reflected by the change from  $15$  to  $12 \text{ mA cm}^{-2}$ ).

Liquid product analysis for the thinnest sample ( $3 \text{ C cm}^{-2}$ ), indicated the formation of formic acid as a non-volatile product (Fig. S6, ESI<sup>†</sup>). The Faradaic efficiency amounts to approximately 20%. We have not evaluated the formic acid formation for the other samples, and will focus the remainder of the discussion on the changes in volatile hydrocarbon composition.

Extensive research on the relation between the structure of copper surfaces and the product composition exists. Single crystal copper electrodes by Hori *et al.* showed that stepped surfaces result in higher selectivity towards ethylene.<sup>39</sup> Introducing (111) steps on to the (100) basal plane increases the formation of ethylene over methane with the highest ethylene/methane ratio of  $\sim 14$  observed on Cu(711).<sup>40</sup> On the other hand, the width of the Cu(100) terraces is suggested to be a decisive factor towards ethylene formation on stepped copper surfaces.<sup>41</sup> Recently Schouten *et al.* proposed that ethylene formation takes place at low overpotentials on Cu(100) through adsorption of CO dimers, whereas at higher potentials both ethylene and methane formation takes place on (100) and (111) facets *via* a shared intermediate.<sup>42</sup> Although we appreciate the effect of surface exposed planes on selectivity, we conclude on the basis of the very similar results obtained for the different  $\text{Cu}_2\text{O}$  morphologies that the structure of the Cu nanoparticles *in situ* formed in electrochemical  $\text{CO}_2$  reduction are not profoundly different. To explain the dramatic changes in selectivity due to increasing layer thickness thus has to have an alternative origin.

Importantly, the CO dimerization mechanism on Cu(100) is enhanced in alkaline media.<sup>43</sup> Therefore, ethylene formation is suggested to take place at conditions of high (local) pH.<sup>41</sup>

Table 1 The capacitance values and surface roughness factors of the films as a function of initial thickness of the films

Charge passed through	Capacitance (mF)	Surface roughness factor
Bare copper	0.14	1
$3 \text{ C cm}^{-2}$	1.6	11
$5 \text{ C cm}^{-2}$	2.4	17
$7 \text{ C cm}^{-2}$	5.1	36
$9 \text{ C cm}^{-2}$	6.1	44
$11 \text{ C cm}^{-2}$	9.1	65

The trend of product selectivity towards hydrocarbons observed here with increasing oxide layer thickness is then explained by local changes in pH during the electrolysis. Gupta *et al.* modeled the local pH changes during the electrochemical CO<sub>2</sub> reduction in KHCO<sub>3</sub> solutions.<sup>44</sup> The local pH near the electrode surface during electrolysis is higher than the bulk value and depends on the applied current density, electrolyte concentration, and stirring speed. The increase in surface roughness and the geometrical current density of the Cu films investigated here, likely lead to an increase in local pH due to the observed increase in hydrogen production (Fig. S7, ESI†) consuming H<sup>+</sup>. The increasing hydrogen FE as a function of film thickness at potentials above  $-1.0$  V vs. RHE is in agreement with the increasing current caused by the presence of the higher surface area, providing additional surface sites for hydrogen evolution. The formation of methane and ethylene have been reported to have a distinctly different pH dependence due to the difference in the involvement of protons in their rate limiting step.<sup>41,45</sup> As a result, at higher (local) pH, the formation of ethylene from the CO intermediate is preferred over the formation of methane. The increase in the current density of hydrogen evolution reaction and local pH changes could therefore possibly explain the decrease and disappearance of methane with the increasing oxide thickness.

Ethane formation so far has only been observed on very rough surfaces, such as electrodeposited foam-like structures,<sup>46</sup> as well as thermally produced oxide films reduced by hydrogenation or electrochemically.<sup>19,45</sup> Recent calculations on C–C coupling on Cu(211) surfaces suggest the kinetic barriers for the coupling are strongly influenced by the degree of the adsorbed CO hydrogenation.<sup>47</sup> These kinetic barriers tend to decrease with increasing degree of the surface bound CO hydrogenation, which can favor ethane. However, the absence of methane formation on the electrodes where ethane is formed suggest the formation is unlikely to occur *via* the formation of adsorbed  $-\text{CH}_3$ , which is proposed as an intermediate for methane formation.<sup>48</sup> The hydrogenation appears to take place after the C–C coupling, such as further reduction of ethylene, in agreement with ethane being formed at the expense of ethylene. Attempts to reduce ethylene on the thickest initial oxide layer electrode directly were unsuccessful due to the broadening and saturation of the ethylene peak in the gas chromatogram, which eventually overlapped with the ethane peak position. However, preliminary OLEMS experiments have demonstrated the hydrogenation of ethylene over Cu surfaces is feasible; results to be published elsewhere.

In order to obtain deeper insight into the role of the cuprous oxide on CO<sub>2</sub> electrochemical reduction, OLEMS studies were conducted on the [111] and [100] oriented films of different thickness. All of the samples prepared by passing 1 to 5 C cm<sup>-2</sup> showed similar catalytic behavior, when analyzed with OLEMS. Therefore, only the 5 C cm<sup>-2</sup> sample is discussed in detail. The CV graphs obtained are shown in Fig. 5, together with the corresponding mass spectroscopy data. Specifically, the very first cathodic sweep is shown in Fig. 5a, whereas the following, second sweep, is shown in Fig. 5b. A clear reductive wave can be

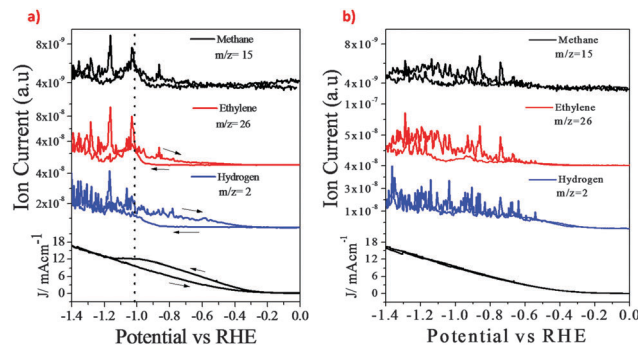


Fig. 5 Ion currents for methane, ethylene, hydrogen probed by OLEMS as a function of applied potential. Cyclic voltammetry curve of oxide films on copper in CO<sub>2</sub> saturated 0.1 M KHCO<sub>3</sub> solution (a) first scan (b) second scan (scan rate 1 mV s<sup>-1</sup>). Arrows indicate the forward and backward scans for clarity.

observed in Fig. 5a, which is absent in Fig. 5b. This is due to the decomposition of electrodeposited cuprous oxide, which starts around  $-0.3$  V vs. RHE. Since this process always proceeds during the initial cathodic sweep, all electrochemical CO<sub>2</sub> reduction proceeds on the newly *in situ* formed metallic copper particles and not on as-deposited Cu<sub>2</sub>O, in agreement with our data presented earlier. The dashed vertical line in Fig. 5a corresponds to the potential where a total charge of 5 C cm<sup>-2</sup> was passed through the electrode for the reduction of the films. Importantly, in the first and the consecutive forward scans no mass fragments corresponding to hydrogen and ethylene were detected, until reaching the conditions needed for the reduction of the films. At the same potentials, appreciable amount of hydrogen and ethylene is produced during the reverse scan, as well as the second and the following sweep cycles.

Copper oxides are known to form spontaneously on copper when exposed to air or electrolyte solution.<sup>49</sup> Intentionally formed Cu<sub>2</sub>O films on copper have been reported to yield methanol with very high FE.<sup>23,50</sup> However, the catalytic activity of these degrades quickly, which is attributed to the decomposition of cuprous oxide to copper, and methanol is considered to be only formed during the reduction of these oxide films. Further, the initial composition of the copper oxide electrocatalyst surface and its transformations during the reduction process are not exactly known. Spectroscopic analysis of spent CO<sub>2</sub> electroreduction electrodes indicate the presence of Cu(I) and Cu(II) oxides after the reaction,<sup>50</sup> but *in situ* analysis is required to verify the existence of the oxide films during the electrocatalytic process. Using OLEMS, no noteworthy amount of methanol was detected from the samples evaluated here. This once again suggests that gaseous CO<sub>2</sub> electrocatalytic reduction products is governed by the copper metal formed from the Cu<sub>2</sub>O films during *in situ* transformations.

## Conclusions

This research highlights the selectivity in electrocatalytic CO<sub>2</sub> reduction of copper nanoparticles derived from different Cu<sub>2</sub>O morphologies and surface coverages. The orientation of

electrodeposited Cu<sub>2</sub>O ([110], [111] and [100]) has only a minor effect on the product selectivity. The initial oxide thickness, however, strongly influences the selectivity of the electrocatalytic process. Specifically, OLEMS studies show that the Cu<sub>2</sub>O reduction itself seems to be highly favored, when compared to CO<sub>2</sub> reduction or water splitting, since no products were detected by online mass spectroscopy on as deposited Cu<sub>2</sub>O. Further, the catalytic behavior is predominantly determined by layer thickness associated local pH changes, impacting the hydrocarbon selectivities. The optimum number density of nanoparticles with the combination of the right electrolyte (pH) can open up routes for highly selective ethylene formation *via* electrochemical reduction of CO<sub>2</sub> in reactors. In addition, gas diffusion electrodes or high pressure can be used to improve CO<sub>2</sub> mass transport.

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